



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q64664

Kiyoshi KAMITANI

Appln. No.: 09/895,264

Confirmation No.: 7751

Filed: July 2, 2001

For: METHOD OF MANUFACTURING LITHOGRAPHIC PRINTING PLATE

AMENDMENT UNDER 37 C.F.R. § 1.111

Commissioner for Patents
Washington, D.C. 20231

Sir:

In response to the Office Action dated May 16, 2002, please amend the above-identified application as follows:

IN THE CLAIMS:

Please cancel claims 4, 7, 8, 10, 11, 15, and 16 without prejudice or disclaimer.

Please enter the following amended claims:

1. (Amended) A method for manufacturing a lithographic printing plate, the method comprising:
conveying a support, on which a photosensitive coating solution containing an organic solvent is coated such that a photosensitive coated layer is formed by the photosensitive coating solution;
drying the photosensitive coated layer by a first heating means to a dry-to-touch state;

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Group Art Unit: 1762

Examiner: Rebecca A. BLANTON

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